Photovoltaic Characteristics of Low-density Concentration GaAs Solar Cells with/without Anti-reflective Coating

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We have studied photovoltaic characteristics of single-junction GaAs solar cells with/without an MgF\textsubscript{2}/ZnS anti-reflective coating (ARC) illuminated by low-density concentration (< 10 suns). By the ARC deposition, the short-circuit current density (\(J_{SC}\)) and the fill factor (FF) are increased by 5 mA/cm\textsuperscript{2} and 5\% at a standard illumination (1 sun), respectively, and the resulted conversion efficiency is enhanced by 45\%. In contrast with the cell with no ARC showing a rapid degradation with increasing concentration power, the efficiency of ARC-deposited cell remains almost constant as (17.7\%±0.3\%) regardless of the concentration. It informs that ARC treatment is very effective in GaAs concentrator solar cells.

Keywords: Solar cell, GaAs, Low-density concentration, Conversion efficiency

I. Introduction

It is widely known that solar cells converting the solar energy to an electric power are not only pro-environmental but highly efficient energy-reproductive devices [1]. Although the solar cell technology have made significant progress in a past few decades, there is still a lack of the conversion efficiency that would greatly benefit by the power applications [2,3]. Up to date, a number of researches has been accomplished competitively with each other for higher cell efficiency by using various material systems, such as Si, GaAs, CIGS (CuInGaSe\textsubscript{2}), DSSC (dye-sensitive solar cell) [4–7]. Though the world record of 40.7\% (240 suns) [7] was recently achieved by a GaAs–based concentrator solar cell, the challenge toward a theoretical limit of 63.1\% [8] is now being continued. (For reference, very recently, Solar Junction Co. announced 43.5\% (400 suns) over the existing record on March 2012 that was approved by the National Renewable Energy Laboratory.)

GaAs compound semiconductor is one of the most suitable materials for solar cells that has a bandgap (\(E_g=1.42\) eV, 300 K) closest to an optimum energy of 1.4 eV, and that is ruled by high-efficient direct transition contrary to Si with an indirect bandgap. The GaAs system has some advantages that make possible tandem devices stacked by their heterostructures [7], and concentrator solar cells available up to \(~1,000\) suns in contrast to Si–based cells with
inherent limit in concentration [9–11]. Recently, an exotic mechanism of the multiple exciton generation (MEG) by a single photon has been proposed as a trial to overcome the Shockley–Queisser limit [12–15]. Many studies are focused on the intermediate band (IB) of an advanced base of MEG, and expanded to quantum–dot based solar cells (QSCs) whose sub–levels would play a decisive role in MEG [14–16]. Although the highest efficiency achieved by QSCs currently remains at ≈20%, it is expected to reach to 25–30% if an inherent problem of carrier trap into QDs would be solved by realization of IB and MEG [17–24].

In this study, we investigate the effect of anti–reflective coating (ARC) [25–28] on concentration characteristics in the matrix solar cell as a preceding study of InAs/GaAs concentrator QSCs. We employ double–stacked [MgF2/ZnS] for an ARC layer and a pair of GaAs solar cells with/without ARC. The refractive index of ARC is analyzed by a spectroscopic ellipsometry, and a homemade concentrator module with a position–variable Fresnel lens is applied to the cells for concentration characteristics (<10 suns). The ARC effect and the concentration dependences of solar parameters are discussed.

II. Experimental Procedures

A single p–n junction GaAs solar cell structure was prepared by a molecular beam epitaxy (MBE) growth system, as sketched in Fig. 1(a). A 1,5–μm–thick n–GaAs:Si (2×10^{17} cm^{–3}) base was grown on n+–GaAs (100) buffer layer, and a 50–nm–thick AlxGa1–xAs:Be(x=0.9) window was inserted between p+–GaAs:Be (2×10^{19} cm^{–3}, 600 nm) emitter and p–contact layer (10 nm). A double–stacked [MgF2/ZnS] ARC layer was deposited on the top surface by a thermal evaporator. Standard photolithography was applied to the device fabrication, and the cell dimension used in this study is [3×3] mm^{2}. The mesa cell was defined by a chemical etchant of [citric acid:H2O=20:1] (~85 nm/s), and a mixture of [HCl+HF] was used for ARC etching. Ohmic contacts for n– and p–type GaAs were formed by and Au/Ge/Ni/Au (26/54/15/200 nm) and Au–Zn/ Ni/Au (80/15/200 nm), followed by rapid thermal annealing at 375°C and 200°C, respectively. Fig. 1(b) shows the device configuration of a single cell ([3×3] mm^{2}) that is composed of six 2,600–nm–long fingers at intervals of 200 nm.

A commercial solar simulator (AM1.5) was employed in measurements for dark and illuminated current–voltage (I–V) curves. For the concentration characteristics under low–density illumination to 10 Po (Po=100 mW/cm^{2}), a homemade concentrator module with a position–variable Fresnel lens (f=22 cm) driven by a linear gear/step motor assembly was utilized with the simulator. The concentration density was controlled by focusing the solar source, and primarily calibrated by a solar power meter (TES–1333R) and a neutral density filter (1%). Sample chuck used in this experiment was designed to keep the cell temperature constant by operating a thermo–electric cooler with a thermocouple. The temperature error was within ±5°C for a measurement duration (~30 s) in atmospheric environment.
III. Results and Discussion

1. Characteristics of [MgF$_2$/ZnS]–ARC

Fig. 2 shows (a) surface AFM images (1×1 μm$^2$) and (b) thickness profiles (Dectak 150) of two individual MgF$_2$ and ZnS layers and a double–stacked [MgF$_2$/ZnS] layer introduced in this study. As plotted in Fig. 2(b), thicknesses of individual MgF$_2$ and ZnS layers are 110 nm and 40 nm, respectively, and that of [MgF$_2$/ZnS] is 130/40 nm. A 20-nm addition in thickness of MgF$_2$ deposited on ZnS is due to the morphological change, as featured in Fig. 2(a). Considering an elongation of the c-axis parameter due to lattice mismatch, MgF$_2$ layer grown on ZnS is expected to be thicker than that grown on GaAs. (The lattice parameter of ZnS (0.54102 nm) is smaller by 4.3% than that of GaAs (0.56533 nm) [29].)

Fig. 2(c) presents the refractive index (n) curves of MgF$_2$ and ZnS analyzed by a spectroscopic ellipsometry. It is confirmed that a pair of spectra simulated from the signal taken from a double–stacked [MgF$_2$/ZnS] layer exactly coincides with those obtained from individual MgF$_2$ and ZnS layers, and the values of 1.39 (MgF$_2$) and 2.31 (ZnS) for a wavelength of 650 nm are the same as known values. While the index of ZnS has a peak value (n=3.35) at 241 nm and gradually approaches to n=2.26 with increasing wavelength, the index of MgF$_2$ remains almost constant as n = 1.40±0.03 in the measurement range (λ=200∼1,000 nm). Anti–reflective wavelength for an ARC layer with a thickness (t) can be calculated by the destructive interference condition of $\lambda$=4nt at perpendicular incidence. The effective wavelengths estimated for MgF$_2$ (t=130 nm) and ZnS (t=40 nm) used in this study are 700 nm and 360∼540 nm, respectively. It indicates that low–index MgF$_2$ and high–index ZnS are mostly effective on anti–reflection at central wavelength (~700 nm) and short wavelength (<540 nm) of the absorption range of GaAs (420∼870 nm). (Refer to Fig. 3(a) for the spectral photoresponse of GaAs solar cell.)

2. Characteristics of GaAs solar cells

A typical photoresponse spectrum taken from a GaAs p–n junction solar cell is shown in Fig. 3(a) in comparison with a simulated one for the same structure. They clearly show that the cutoff wavelength is about 870 nm corresponding to the bandgap energy of GaAs (1.42 eV). Differently from the simulated data gradually changing near 400 nm, the experimental curve shows a saturating behavior, which is due to a detection limit of the measurement system used in this study. Fig. 3(b) is the current den-
Table 1. Summary of the solar parameters measured at 100 mA/cm² (AM 1.5) for GaAs cells without/with ARC and the simulated values.

<table>
<thead>
<tr>
<th>Samples</th>
<th>Solar cell parameters</th>
<th></th>
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<tbody>
<tr>
<td></td>
<td>( V_{oc} ) (V)</td>
<td>( J_{sc} ) (mA/cm²)</td>
</tr>
<tr>
<td>Without ARC</td>
<td>Experimental</td>
<td>0.938</td>
</tr>
<tr>
<td></td>
<td>Simulated</td>
<td>1.04</td>
</tr>
<tr>
<td>With ARC</td>
<td>Experimental</td>
<td>1.00</td>
</tr>
</tbody>
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Figure 5. Plots of (a) FF and (b) η for the cells with/without ARC as a function of concentration ratio (P/P₀).

The data plotted in Fig. 5(b) are the conversion efficiency (η) estimated from the values of VOC and FF presented in Figs. 4 (a) and 4(b) by using the equation below:

$$\eta = P_{\text{out}} / P_{\text{in}} = \text{FF} \times [(J_{\text{SC}} / P_{\text{in}}) \times V_{\text{OC}}].$$

Here, P_{\text{in}} is the input solar power density illuminated by the simulator, and P_{\text{out}} is the output electric power density generated by the cell under test, FF × [J_{\text{SC}} × V_{\text{OC}}]. The factor of (J_{\text{SC}} / P_{\text{in}}) in Eq.(1), J_{\text{SC}} normalized to the input power density, has a constant value as 22.1/17.2 mA/cm² for the cells with/without ARC. Two curves indicate that the efficiency is enhanced by 5~6% by ARC deposition, and the difference becomes larger with increasing concentration power. In addition, the solar cell does not exhibit any improvement in the conversion efficiency by low-density concentration due to increase of serial resistance. However, they clearly demonstrate the effect of [MgF₂/ZnS]—ARC in GaAs solar cells with highly reflective surface and a limit of single-junction structures [5].

**IV. Summary and Conclusions**

We have characterized the spectroscopic refractive index of a double–stacked [MgF₂/ZnS]—ARC layer and the solar parameters of single–junction GaAs solar cells with/without ARC for low–density concentration (<10 suns). The ellipsometric spectra showed that...
the refractive index of MgF2 remained almost constant as \( n=1.40 \pm 0.03 \) in the range of \( \lambda=200\sim1,000 \) nm, and that of ZnS gradually decreased to \( n=2.26 \) (\( \lambda\sim1,000 \) nm) from a peak value \( n=3.35, \lambda=241 \) nm). It informed that ARCs of low-index MgF2 and high-index ZnS used in this study were effective on anti-reflection at central wavelength (\( \sim700 \) nm) and short wavelength (\( <540 \) nm) of the absorption range of GaAs, respectively.

The short-circuit current density (\( J_{SC} \)) and the fill factor (\( FF \)) of GaAs solar cells were enhanced by 5 mA/cm\(^2\) and 5\% by ARC deposition at a standard illumination (1 sun), respectively, and the resulted efficiency (\( \eta \)) was increased by 45\%. The efficiency of the cell with no ARC rapidly decreased with increased concentration power, but that of the ARC-deposited cell almost remained constant at (17.7\pm0.3)\%. It assured that the ARC treatment considerably enhanced the device performance of GaAs solar cell with highly reflective surface, especially under the concentration environment that the carrier recombination became dominated.

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References


